



27W  
AFS

**PATENT APPLICATION**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q80136

Yoshitaka MIYAKE

Appln. No.: 10/790,124

Group Art Unit: 1713

Confirmation No.: 1136

Examiner: Bernard Lipman

Filed: March 2, 2004

For: POLYVINYL ACETAL RESIN FOR HEAT-DEVELOPABLE PHOTSENSITIVE MATERIAL AND HEAT-DEVELOPABLE PHOTSENSITIVE MATERIAL

**NOTICE OF APPEAL**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicant hereby appeals to the Board of Patent Appeals and Interferences from the final Office Action dated November 10, 2005.

The USPTO is directed and authorized to charge the statutory fee of \$500.00 to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

\_\_\_\_\_  
Joseph J. Ruch, Jr.

SUGHRUE MION, PLLC  
Telephone: (202) 293-7060  
Facsimile: (202) 293-7860

Registration No. 10/790,124 00000064 194880 10790124  
01 FC:1401 500.00 DA

WASHINGTON OFFICE

**23373**

CUSTOMER NUMBER

Date: May 10, 2006